

Stabilizing the inverted phase of a WSe₂/BLG/WSe₂ heterostructure via hydrostatic pressure

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Bilayer graphene (BLG) was recently shown to host a band-inverted phase with unconventional topology emerging from the Ising-type spin-orbit interaction (SOI) induced by the proximity of transition metal dichalcogenides with large intrinsic SOI. Here, we report the stabilization of this band-inverted phase in BLG symmetrically encapsulated in tungsten-diselenide (WSe₂) via hydrostatic pressure. Our observations from low temperature transport measurements are consistent with a single particle model with induced Ising SOI of opposite sign on the two graphene layers. To confirm the strengthening of the inverted phase, we present thermal activation measurements and show that the SOI-induced band gap increases by more than 100% due to the applied pressure. Finally, the investigation of Landau level spectra reveals the dependence of the level-crossings on the applied magnetic field, which further confirms the enhancement of SOI with pressure.

Van der Waals (VdW) engineering provides a powerful method to realize electronic devices with novel functionalities via the combination of multiple 2D materials [1]. An exciting example is the case of graphene connected to materials with large intrinsic spin-orbit interaction (SOI), which allows the generation of an enhanced SOI in graphene via proximity effect [2–26]. This, on the one hand, is compelling in the case of spintronics devices since the large spin diffusion length in graphene heterostructures [27–29] could be complemented with electrical tunability [30–32] or charge-to-spin conversion effects [33]. Moreover, it is also interesting from a fundamental point of view since graphene with intrinsic SOI was predicted to be a topological insulator [34]. The observation of increased SOI was demonstrated in the last few years in both single layer [12–20] and recently in bilayer graphene (BLG) [14, 21–26]. It was found that one of the dominating spin-orbit terms is the Ising-type valley-Zeeman term which is an effective magnetic field acting oppositely in the two valleys, and could enable such exciting applications as a valley-spin valve in BLG [35]. Recent compressibility measurements [21] have shown that BLG encapsulated in tungsten-diselenide (WSe₂) from both sides hosts a band-inverted phase if the sign of induced SOI is different for the two WSe₂ layers. In practice, this can be achieved if the twist angle between the two WSe₂ layers is 180° [7, 11, 36].

In this paper, we experimentally investigate the SOI induced in BLG symmetrically encapsulated in WSe₂ (WSe₂/BLG/WSe₂) via transport measurements. We present resistance measurements as a function of charge carrier density (n) and transverse displacement field (D) at ambient pressure and demonstrate the appearance of

the inverted phase (IP). In order to stabilize this phase, we employ our recently developed setup [37, 38] to apply a hydrostatic pressure (p) which allows us to boost the SOI as we have recently demonstrated on single layer graphene [39]. To confirm the increased SOI, we present thermal activation measurements where the evolution of the SOI-induced band gap can be estimated as a function of D and p . Finally, we further investigate the induced SOI with quantum Hall measurements by tracking the Landau level crossings as a function of magnetic field.

To reveal the band-inverted phase arising from the Ising SOI in BLG, we show the low-energy band structure of WSe₂/BLG/WSe₂ in Fig. 1, calculated using a continuum model by following in the footsteps of Ref. [7]. The effect of the WSe₂ layers in proximity of BLG can be described by the Ising SOI terms λ_I^t and λ_I^b that couple only to the top or bottom layer of BLG and act as a valley-dependent effective magnetic field. For WSe₂ layers rotated with respect to each other with 180°, the induced SOI couplings will have opposite sign [7, 11, 36]. This is taken into account by the opposite sign of λ_I^t and λ_I^b . The transverse displacement field (D) in our measurements can be modelled by introducing an interlayer potential difference $u = \frac{-ed}{\epsilon_0 \epsilon_{BLG}} D$, where e is the elementary charge, ϵ_0 is the vacuum permittivity, $d = 3.3 \text{ \AA}$ is the separation of BLG layers and ϵ_{BLG} is the effective out-of-plane dielectric constant of BLG.

Fig. 1.a-c show the calculated band structure around the \mathbf{K} -point for different values of u , using the parameter values $\lambda_I^t = -\lambda_I^b = 2 \text{ meV}$. Details of the modeling can be found in the Supporting Information. First of all, for $|u| > |\lambda_I^t| = |\lambda_I^b|$, we can see the opening of a band gap (Fig. 1.a), as expected for BLG in a transverse displace-

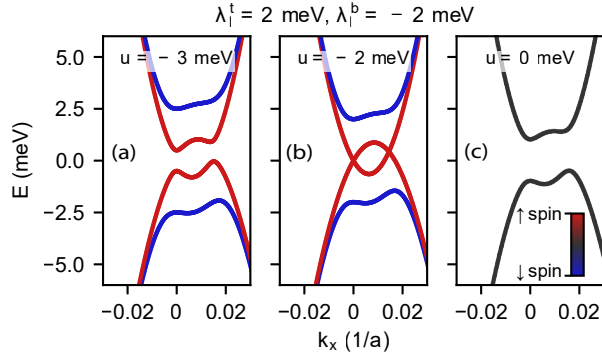


FIG. 1. a-c) Calculated band structure around the \mathbf{K} -point for different values of the interlayer potential difference u . Color scale corresponds to the spin polarization of the bands.

ment field [40, 41]. On the other hand, as opposed to pristine BLG, the bands are spin-split and the direction of this spin splitting is opposite for the valence and conduction bands. This is a direct consequence of the opposite sign of λ_I^t and λ_I^b as the valence and conduction bands are localised on different layers due to the large u . The band structure in the \mathbf{K}' -valley is similar, except that the spin-splitting is reversed due to time reversal symmetry. For $|u| = |\lambda_I^{t,b}|$ (Fig. 1.b), the u -induced band gap approximately equals the spin splitting induced by the Ising SOI and the bands touch. Finally, for $|u| < |\lambda_I^{t,b}|$ (Fig. 1.c), a band gap re-opens and we observe spin-degenerate bands for $u = 0$, separated by a gap comparable in size to the Ising SOI terms ($\Delta \approx |\lambda_I^t - \lambda_I^b|/2$). This gapped phase is distinct from the band insulating phase at large u in that the valence and conduction bands are no longer layer polarised, hence it is usually referred to as inverted phase (IP). It is worth mentioning that the IP at $|u| < |\lambda_I^t|$ is weakly topological unlike the trivial band insulating phase [42, 43].

Our device consists of a BLG flake encapsulated in WSe₂ and hexagonal boron nitride (hBN) on both sides, as it is illustrated in Fig. 2.a. To enable transport measurements, we fabricated NbTiN edge contacts in a Hall bar geometry. The device also features a graphite bottomgate and a metallic topgate that allow the independent tuning of n and D . See Supporting Information for more details about sample fabrication and geometry.

Fig. 2.c shows the resistance measured in a four-terminal geometry as a function of n and D at ambient pressure at 1.4 K temperature. As expected for BLG, we observe the opening of a band gap at large displacement fields along the charge neutrality line (CNL) at $n = 0$, indicated by an increase of resistance. In accordance with the theoretical model and previous compressibility measurements [21], we also observe two local minima separated by a resistance peak at $D = 0$ in agreement with the closing and re-opening of the band gap signalling the transition between the band insulator and the IP. This observation is further emphasized in Fig. 2.b, where a line

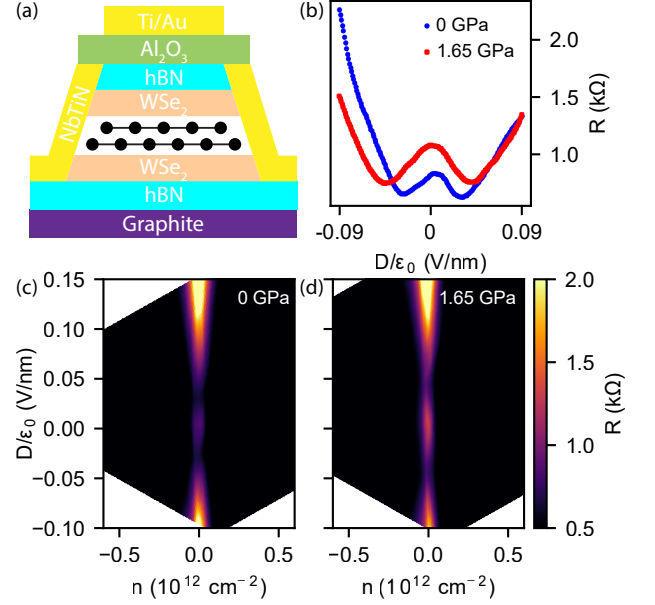


FIG. 2. a) Schematic representation of the measured device. Bilayer graphene is symmetrically encapsulated in WSe₂ and hBN. b) Line trace of the four-terminal resistance along the CNL for ambient pressure (blue) and $p = 1.65$ GPa (red). c,d) Four-terminal resistance map as a function of charge carrier density n and displacement field D measured at c) ambient pressure and d) an applied pressure of 1.65 GPa. The alternating low and high resistance regions along the CNL indicate the closing and re-opening of a band gap in the bilayer graphene.

trace (blue) of the resistance is shown as a function of D , measured along the CNL.

To boost the induced SOI and stabilize the IP, we applied a hydrostatic pressure of $p = 1.65$ GPa and repeated the previous measurement. Fig. 2.d shows the n - D map of the resistance after applying the pressure. Although the basic features of the resistance map are similar, two consequences of applying the pressure are clearly visible. First, as it is also illustrated in Fig. 2.b, the peak resistance in the IP at $D = 0$ increased by $\sim 25\%$. Secondly, the displacement field required to close the gap of the IP increased significantly, by about 70%. Both of these observations can be accounted for by an increase of the Ising SOI term that results in a larger gap at $D = 0$ and subsequently in a larger displacement field needed to close the gap. Although the shift of resistance minima could be explained by the increase of ϵ_{BLG} or the decrease of interlayer separation d , these altogether are not expected to have greater effect than $\sim 20\%$ [44]. It is also worth mentioning that the lever arms also change due to the applied pressure, changing the conversion from gate voltages to n and D , however, we have corrected for this effect by experimentally determining them from quantum Hall measurements (see Supporting Information).

To quantify the increase of SOI gap due to hydro-

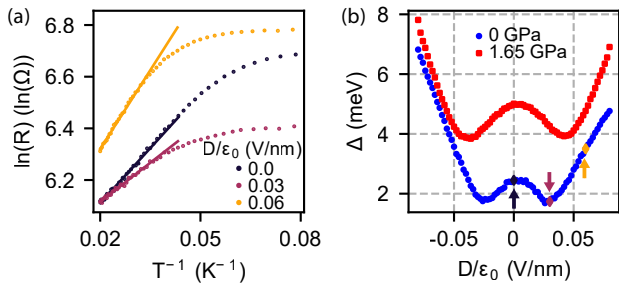


FIG. 3. Thermal activation measurements along the charge neutrality line. a) Arrhenius plot of the resistance at ambient pressure for selected values of D . Solid lines are fits to the linear parts of the data from which the band gap values were obtained. b) Gap Δ as a function of displacement field at ambient pressure (blue) and an applied pressure of 1.65 GPa. Arrows indicated the D values for which the activation data is shown in a).

static pressure, we performed thermal activation measurements along the CNL for several values of D . Fig. 3.a demonstrates the evolution of resistance as a function of $1/T$ for selected values of D at ambient pressure. From this, we extract the band gap using a fit to the high-temperature, linear part of the data where thermal activation $-\ln(R) \propto \Delta/2k_B T$ dominates over hopping-related effects [45]. Fig. 3.b shows the extracted gap values as a function of D with and without applied pressure. First of all, a factor of 2 increase is clearly visible in the gap at $D = 0$ for $p = 1.65$ GPa, that is consistent with the observed increase of resistance. Secondly, the higher D needed to reach the gap minima is also confirmed. We also note that the band gap cannot be fully closed which we attribute to spatial inhomogeneity in the sample.

The experimentally determined band gaps allow us to quantify the SOI parameters. By adjusting the theoretical model to match the positions of the gap minima for $p = 0$, we extract $\lambda_I^t = -\lambda_I^b = 2.2 \pm 0.4$ meV. Since we do not expect d to change substantially due to pressure, by fixing its value to 3.3 Å, we can extract the SOI parameters at $p = 1.65$ GPa as well. For these, we obtain $\lambda_I^t = -\lambda_I^b = 5.6 \pm 0.6$ meV. A more detailed discussion on the extraction and possible errors is given in the Supporting Information.

The quantum Hall effect in BLG provides us another tool to investigate the Ising SOI induced by the WSe₂ layers. The two-fold degeneracy of valley isospin ($\xi = +, -$), the first two orbitals ($N = 0, 1$) and spin ($\sigma = \uparrow, \downarrow$) give rise to an eight-fold degenerate Landau level (LL) near zero-energy [46–48]. This degeneracy is weakly lifted by the interlayer potential difference, Zeeman energy, coupling elements between the BLG layers [49] and the induced Ising SOI [22]. We can obtain the energy spectrum of this set of eight closely-spaced sublevels – labeled by $|\xi, N, \sigma\rangle$ – by introducing a perpendicular magnetic field in our continuum model, as detailed in [49]. This is shown

in Fig. 4.a for $B = 8.5$ T as a function of the interlayer potential (u). LLs with different ξ reside on different layers of the BLG, therefore u induces a splitting between these levels. Secondly, the finite magnetic field causes the Zeeman-splitting of levels with different σ . Finally, the Ising SOI induces an additional effective Zeeman field associated to a given layer, further splitting the levels. The key feature that should be noted here, is that for a given filling factor ν , crossings of LLs can be observed and the position of crossing points along the u axis depend on SOI parameters as well as on the magnetic field. These level crossings manifest as sudden changes of resistance in our transport measurements as it is illustrated in Fig. 4.b. Here, the $n - D$ map of the resistance is shown as measured at $B = 8.5$ T with fully developed resistance plateaus (due to the unconventional geometry, see Supporting Information) corresponding to the sublevels of $\nu \in [-4, 4]$. For a given filling factor ν , we observe $4 - |\nu|$ different D values where the resistance deviates from the surrounding plateau corresponding to the crossing of LLs, as expected from the model.

The evolution of LL crossings with B can be observed by performing measurements at fixed filling factors, as it is shown in Fig. 4.c and 4.e for $\nu = 0$ and $\nu = 1$, respectively. During the latter measurement, the carrier density n was tuned such that the filling factor given by $\nu = nh/eB$ was kept constant. On both panels, we can observe $4 - \nu$ LL crossings that evolve as B is tuned, until they disappear at low magnetic fields where we can no longer resolve LL plateaus. This B -dependent behaviour enables us to investigate the effect of SOI on the LL structure. Fig. 4.d and 4.f shows the critical displacement field D^* values – where LL crossings can be observed – extracted from Fig. 4.c and 4.e and similar maps measured at $p = 1.65$ GPa (see Supporting Information). For $\nu = 0$ (Fig. 4.d), the most important observation is that the crossing points do not extrapolate to zero as $B \rightarrow 0$ T which is a direct consequence of the induced Ising SOI. It is also clearly visible that due to the applied pressure, $|D^*|$ is generally increased, especially at lower B -fields, indicating that the Ising SOI has increased, in agreement with our thermal activation measurements. For $\nu = 1$ (Fig. 4.f), similar trends can be observed. The two LL crossings at finite D saturate for small B , while the third crossing remains at $D = 0$. We note that the $D^*(B)$ curves for $p = 1.65$ GPa cannot be scaled down to the $p = 0$ curves, which confirms that our observations cannot simply be explained by an increased ϵ_{BLG} or decreased interlayer separation distance, but are the results of enhanced SOI. We also point out that some lines which extrapolate to $D = 0$ can also be observed (e.g. Fig. 4.e, grey arrow). This could also be explained by sample inhomogeneity. It is also important to note that our single-particle model fails to quantitatively predict the B -dependence of the LL crossings indicating the importance of electron-electron interactions (see Supporting Information).

In conclusion, we showed that the IP observed in BLG

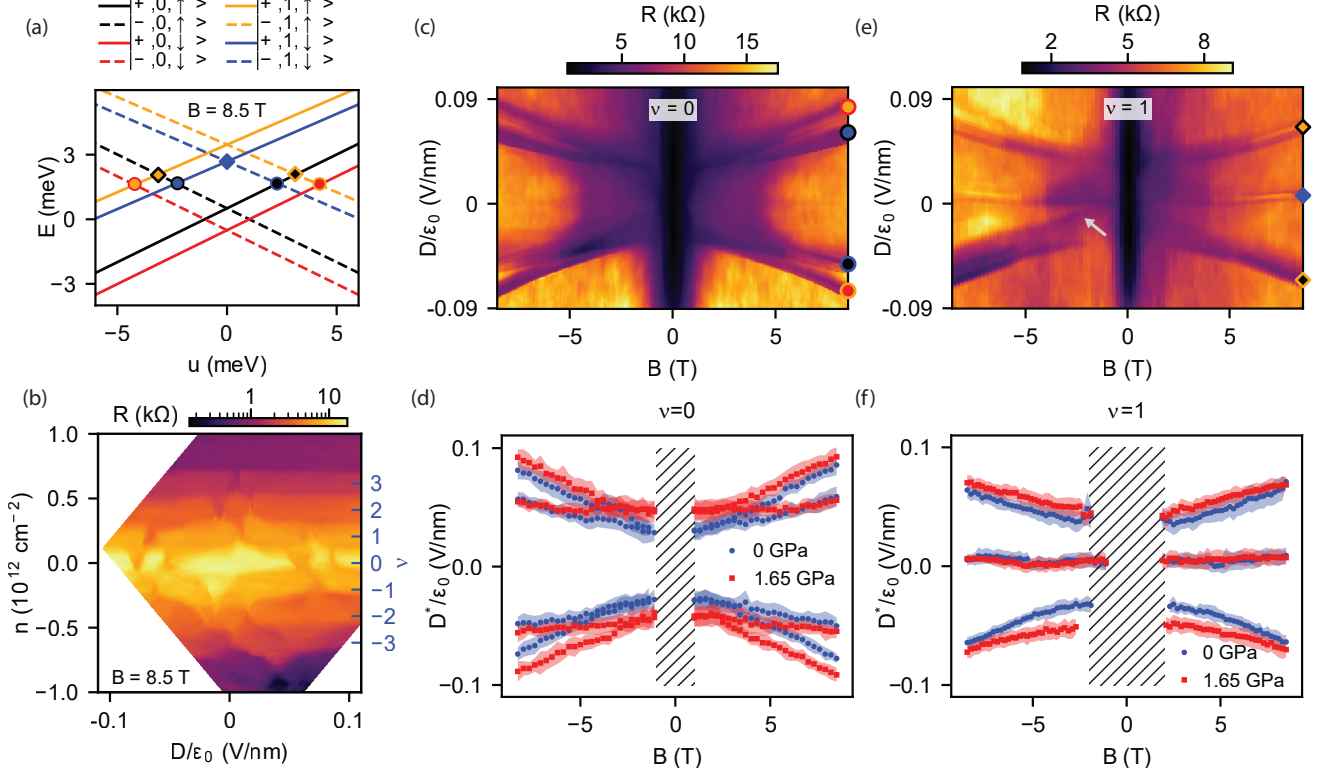


FIG. 4. a) Low energy Landau level spectrum at $B = 8.5$ T obtained from single-particle continuum model with $\lambda_I^t = -\lambda_I^b = 2$ meV. b) Four-terminal resistance as a function of n and D measured at $B = 8.5$ T out-of-plane magnetic field and ambient pressure. Resistance plateaus correspond to different ν filling factors. Abrupt changes in resistance at a given ν as a function of D indicate the crossings of LLs. c,e) Measurements of LL crossings as a function of B for $\nu = 0$ and $\nu = 1$, respectively, for $p = 0$. Symbols denote LL crossings shown in (a). d,f) Critical displacement field D^* corresponding to LL crossings for $\nu = 0$ and $\nu = 1$ extracted from $D - B$ maps measured at $p = 0$ (blue, see (c,e)) and $p = 1.65$ GPa (red).

symmetrically encapsulated between twisted WSe_2 layers can be stabilized by applying hydrostatic pressure which enhances the proximity induced SOI. We presented thermal activation measurements as a means to quantify the Ising SOI parameters in this system and showed an increase of approximately 150% due to the applied pressure. In order to gain more information on the twist angle dependence of the SOI, a more systematic study with several samples with well-controlled twist angles is needed. The enhancement of Ising SOI with pressure was further confirmed from quantum Hall measurements. However, to extract SOI strengths from these measurements, more complex models are needed that also take into account interaction effects. Our study shows that the hydrostatic pressure is an efficient tuning knob to control the induced Ising SOI, thereby the topological phase in $\text{WSe}_2/\text{BLG}/\text{WSe}_2$.

The IP has a distinct topology from the band insulator phase at large D , and the presence of edge states are expected [42]. The presence of these states should be studied in better defined sample geometries [50, 51] or using supercurrent interferometry [52, 53]. Opposed to the weak protection of the edge states in this system, a strong topological insulator phase is predicted in

ABC trilayer graphene [43, 54]. Furthermore, pressure could also be used in case of magic-angle twisted BLG, in which topological phase transitions between different Chern insulator states are expected as a function of SOI strength [55].

AUTHOR CONTRIBUTIONS

N.P. and P.K.R. fabricated the device. Measurements were performed by M.K., B.Sz., P.K.R. with the help of M.A., P.M. M.K. and B.Sz. did the data analysis. B.Sz. did the theoretical calculation. M.K., B.Sz. and E.T. and P.M. wrote the paper and all authors discussed the results and worked on the manuscript. K.W. and T.T. grew the hBN crystals. The project was guided by Sz.Cs., S.G. and P.M.

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Supporting Information

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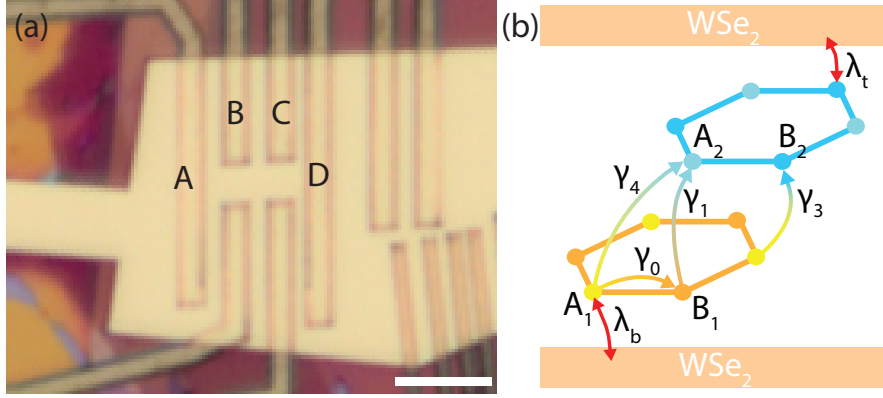


FIG. S1. (a) Optical image of the measure device. The scale bar is $4 \mu\text{m}$. (b) Schematic illustration of the heterostructure, showing the hopping terms in the BLG and the layer dependent SOC terms, induced by the WSe_2 layers.

S1. DEVICE GEOMETRY AND MEASUREMENT SETUP

The measured device is shown in Fig. S1. The dry-transfer technique with PC/PDMS hemispheres is employed to stack hBN (35 nm)/ WSe_2 (19 nm)/BLG/ WSe_2 (19 nm)/hBN (60 nm)/graphite. To fabricate electrical contacts to the Hall bar, we use e-beam lithography patterning followed by a reactive ion etching step using CHF_3/O_2 mixture and finally deposit Ti (5nm)/NbTiN (100 nm) by dc sputtering. We deposit Al_2O_3 (30 nm) using ALD which acts as the gate dielectric. Finally, the top gate is defined by e-beam lithography and deposition of Ti (5 nm)/Au (100 nm).

Transport measurements were carried out in an Oxford cryostat equipped with a variable temperature insert (VTI) at a base temperature of 1.4 K (unless otherwise stated). Measurements were performed using lock-in technique with 0.1 mV AC voltage excitation at 1171 Hz frequency. The AC voltage bias was applied between contacts A and D while the four-terminal voltages were measured between B and C.

S2. CONTINUUM MODEL OF WSE2/BLG/WSE2

A. Low-energy Hamiltonian

We model the studied heterostructure with the low-energy Hamiltonian of bilayer graphene with an additional spin-orbit coupling term, which is different on the two graphene layers, induced by the proximity of the two WSe₂ layers. In the basis of the 4 atom unit cell, ($|C_{A1}\rangle, |C_{B1}\rangle, |C_{A2}\rangle, |C_{B2}\rangle$) \otimes ($|\uparrow\rangle, |\downarrow\rangle$) the Hamiltonian is written as

$$\mathcal{H} = \mathcal{H}_{\text{BLG}} + \mathcal{H}_{\text{SOC}}, \quad (\text{S1})$$

$$\mathcal{H}_{\text{BLG}} = \begin{pmatrix} u/2 & v_0\pi^\dagger & -v_4\pi^\dagger & v_3\pi \\ v_0\pi & u/2 + \Delta' & \gamma_1 & -v_4\pi^\dagger \\ -v_4\pi & \gamma_1 & -u/2 + \Delta' & v_0\pi^\dagger \\ v_3\pi^\dagger & -v_4\pi & v_0\pi & -u/2 \end{pmatrix} \otimes s_0, \quad (\text{S2})$$

$$\mathcal{H}_{\text{SOC}} = \begin{pmatrix} \xi\lambda_I^b s_z/2 & i\lambda_R^b s_-^\xi & 0 & 0 \\ -i\lambda_R^b s_+^\xi & \xi\lambda_I^b s_z/2 & 0 & 0 \\ 0 & 0 & \xi\lambda_I^t s_z/2 & i\lambda_R^t s_-^\xi \\ 0 & 0 & -i\lambda_R^t s_+^\xi & \xi\lambda_I^t s_z/2 \end{pmatrix}, \quad (\text{S3})$$

where \mathcal{H}_{BLG} is the Hamiltonian of the BLG[S1] and \mathcal{H}_{SOC} is the spin-orbit coupling term describing the proximity induced Ising-type SOC with the parameters of λ_I^i and Rashba-type SOC parametrized with λ_R^i [S2, S3]. Here, s_i , with $i = \{0, x, y, z\}$, are the spin Pauli matrices and $s_\pm^\xi = \frac{1}{2}(s_x + i\xi s_y)$. In \mathcal{H}_{BLG} , γ_i , with $i = \{0, 1, 3, 4\}$ describe the intra- and interlayer hoppings in BLG, as illustrated in Fig. S1.b, $v_i = \sqrt{3}a\gamma_i/2\hbar$ are effective velocities, with the lattice constant of the graphene $a = 2.46 \text{ \AA}$ and Δ' is the dimer on-site energy. γ_0 is the nearest neighbour intralayer hopping, γ_1 is the interlayer hopping between the dimer sites, γ_3 describes the hopping between the non-dimer sites and γ_4 is the interlayer hopping between the dimer and non-dimer orbitals. In \mathcal{H} , $\pi = \hbar(\xi k_x + ik_y)$ and $\pi^\dagger = \hbar(\xi k_x - ik_y)$ are momentum operators measured from the K and K' valleys with the valley indices $\xi = \pm 1$. The parameter u is the interlayer potentials difference modelling the effect of an external electric field.

In our simulations we have used the following parameters: $\gamma_0 = 2.61 \text{ eV}$, $\gamma_1 = 0.361 \text{ eV}$, $\gamma_3 = 0.283 \text{ eV}$, $\gamma_4 = 0.138 \text{ eV}$ and $\Delta' = 0.015 \text{ eV}$ [S4].

In the main text, we show the spectrum near the K valley. Here, we show the difference

between the K and K' valleys in Fig S2. The main difference, besides the opposite tilting due to the trigonal warping, is the opposite spin polarization of the bands, which is the manifestation of the Kramers theorem, since the Valley Zeemann terms generates an opposite effective magnetic field in the two valleys. In the figures, we calculate the spin polarization as

$$\zeta_n = \sum_{X=A1,A2,B1,B2} |c_{X,\uparrow}|^2 - |c_{X,\downarrow}|^2. \quad (\text{S4})$$

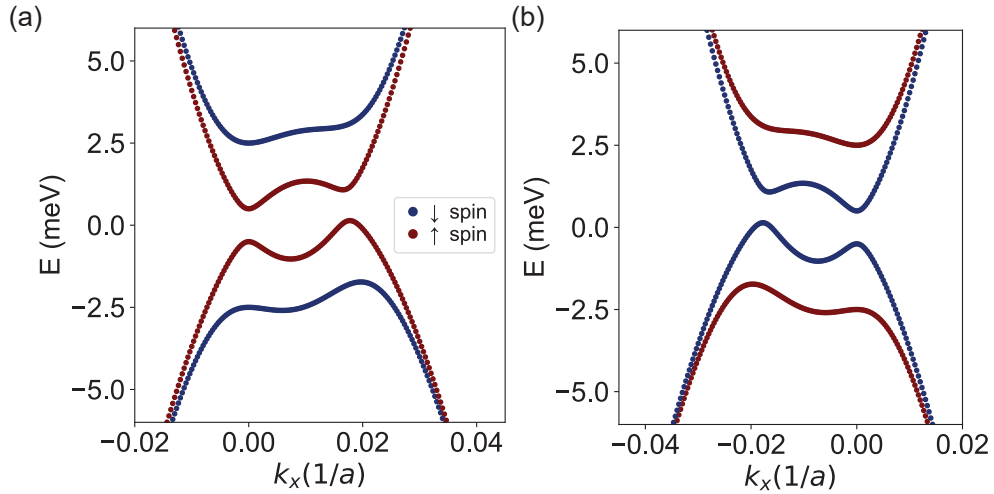


FIG. S2. Calculated band structure using the parameters of $u = 3 \text{ meV}$ and $\lambda_I^b = -\lambda_I^t = 2 \text{ meV}$ (a) near the K valley and (b) near the K' valley.

Besides the spin polarization, the layer polarization α_n is also an important parameter of the model, which is defined as

$$\alpha_n = \sum_{s=\uparrow,\downarrow} |c_{A1,s}|^2 + |c_{B1,s}|^2 - |c_{A2,s}|^2 - |c_{B2,s}|^2. \quad (\text{S5})$$

As shown in Fig. S3. at $u = 0$ the bands have no layer polarization, which can be lifted by increasing u . For $|u| > |\lambda_I^b|$, the low energy part of the conduction and valence bands becomes layer polarized with the opposite layer polarization of the valence and conduction bands.

For completeness, the band structure near the K -point is shown in Fig. S4. with $\lambda_I^b = \lambda_I^t$. In this case, the bands are spin split due to the SOC, which can be considered here as a Zeemann splitting in an effective magnetic field. Moreover, in this case, there is no gap at $u = 0$ and a gap only opens if $|u| > |\lambda_I^{b,t}|$.

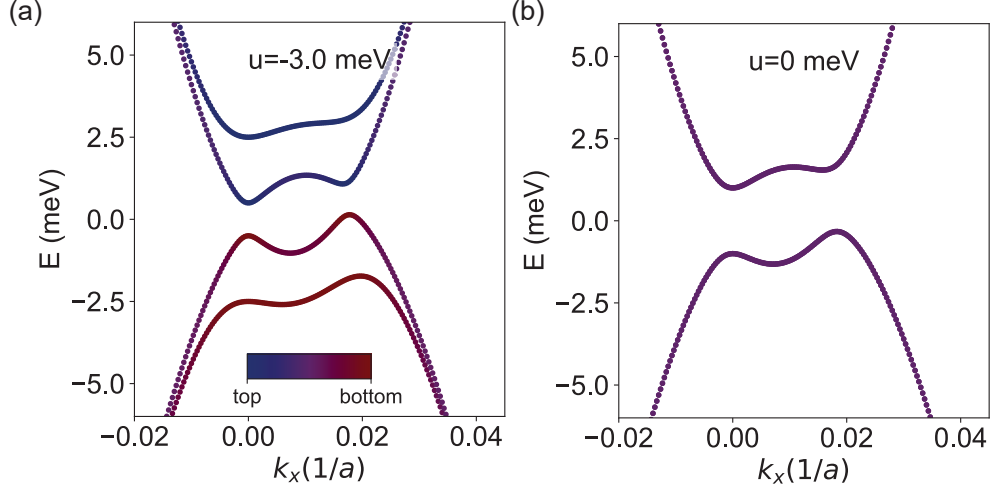


FIG. S3. Calculated band structure using the parameter of $\lambda_I^b = -\lambda_I^t = 2$ meV (a) at $u = -3$ meV and (b) at $u = 0$ meV. The color of the line corresponds to the layer polarization: the blue (red) points are fully polarized to the top (bottom) layer and the purple points are layer degenerated.

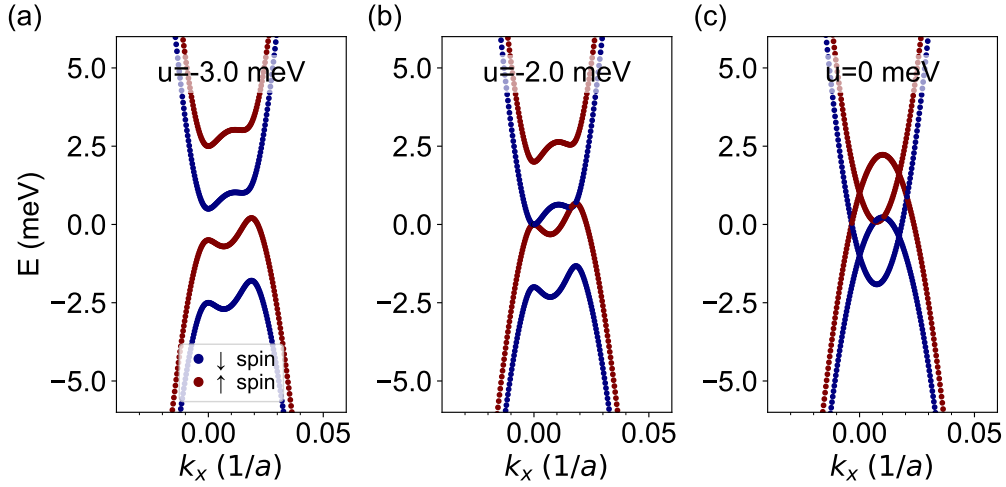


FIG. S4. Calculated band structure using the parameter of $\lambda_I^b = \lambda_I^t = 2$ meV (a) at $u = -3$ meV, (b) at $u = -2$ meV and (c) at $u = 0$ meV. The color of the lines corresponds to the spin polarization.

B. Landau level calculations

In high perpendicular magnetic field B , we replace the canonical impulse with the kinetic momentum $\hbar q_i = \hbar k_i - eA_i$, where A_i is the vector potential and introduce the magnetic ladder operators as $\hat{a} = \sqrt{\frac{\hbar}{2eB}}(q_x + iq_y)$ and $\hat{a}^\dagger = \sqrt{\frac{\hbar}{2eB}}(q_x - iq_y)$, which satisfy $[\hat{a}, \hat{a}^\dagger] = 1$. In Eq. S2, we replace π and π^\dagger with the ladder operators as $\pi = \sqrt{2eB\hbar}\hat{a}$ and $\pi^\dagger = \sqrt{2eB\hbar}\hat{a}^\dagger$

for the K valley and $\pi = -\sqrt{2eB\hbar}\hat{a}^\dagger$ and $\pi^\dagger = -\sqrt{2eB\hbar}\hat{a}$ for the K' valley. We neglect γ_3 in the Landau level (LL) calculations, which would introduce a small mixing of the zero LLs and the higher LLs. For the K valley the \mathcal{H}_{BLG} can be rewritten as

$$\mathcal{H}_{\text{BLG}}^K = \begin{pmatrix} u & v_0\sqrt{2eB\hbar}\hat{a}^\dagger & -v_4\sqrt{2eB\hbar}\hat{a}^\dagger & 0 \\ v_0\sqrt{2eB\hbar}\hat{a} & u + \Delta' & \gamma_1 & -v_4\sqrt{2eB\hbar}\hat{a}^\dagger \\ -v_4\sqrt{2eB\hbar}\hat{a} & \gamma_1 & -u + \Delta' & v_0\sqrt{2eB\hbar}\hat{a}^\dagger \\ 0 & -v_4\sqrt{2eB\hbar}\hat{a} & v_0\sqrt{2eB\hbar}\hat{a} & -u \end{pmatrix} \otimes s_0, \quad (\text{S6})$$

and for K' valley it is given by

$$\mathcal{H}_{\text{BLG}}^{K'} = \begin{pmatrix} u & -v_0\sqrt{2eB\hbar}\hat{a} & v_4\sqrt{2eB\hbar}\hat{a} & 0 \\ -v_0\sqrt{2eB\hbar}\hat{a}^\dagger & u + \Delta' & \gamma_1 & v_4\sqrt{2eB\hbar}\hat{a} \\ v_4\sqrt{2eB\hbar}\hat{a}^\dagger & \gamma_1 & -u + \Delta' & -v_0\sqrt{2eB\hbar}\hat{a} \\ 0 & v_4\sqrt{2eB\hbar}\hat{a}^\dagger & -v_0\sqrt{2eB\hbar}\hat{a}^\dagger & -u \end{pmatrix} \otimes s_0. \quad (\text{S7})$$

The full Hamiltonian in B field is also expanded with the Zeeman term $\mathcal{H}_Z = E_Z s_z$, where $E_Z = -\mu_B B$ is the Zeeman energy with the Bohr magneton μ_B . The eigenenergies E_{ξ,n,s_z} of $\mathcal{H} = \mathcal{H}_{\text{BLG}} + \mathcal{H}_{\text{SOC}} + \mathcal{H}_Z$ are defined as

$$\mathcal{H} |\xi, n, \sigma\rangle = E_{\xi,n,s_z} |\xi, n, \sigma\rangle, \quad (\text{S8})$$

with the eigenstates of $|\xi, n, \sigma\rangle$. The ladder operators act on the Landau level wavefunctions as $\hat{a} |n\rangle = \sqrt{n} |n-1\rangle$ and $\hat{a}^\dagger |n+1\rangle = \sqrt{n+1} |n+1\rangle$. Following the footsteps of [S5], the same ansatz can be used to solve Eq. S8, which was used with induced SOC only in one graphene layer.

By solving the eigenvalue problem, the single-particle Landau level energies can be obtained. In Fig. 4a. in the main text, we plot the lowest 8 LLs with respect to u at $B = 8.5$ T. These LLs would be degenerate if we set every parameter to zero except γ_0 and γ_1 , including the interlayer potential. In Fig. S5 we show the LLs in three different scenarios of λ_I : in panel (b) the LLs are shown if $\lambda_I = 0$. In this case, the LLs are spin split due to the Zeeman term and also split in the orbital index due to γ_0 and Δ' . A finite u further splits these LLs and their energy is linear in u . Since for the two lowest LL the spin and layer index becomes effectively the same, different valleys shift oppositely with a displacement field. By introducing a finite Ising-type SOC λ_I^b shifts the energies of the eigenstates of $|K, n, \sigma\rangle$ and λ_I^t shifts the energies of the eigenstates of $|K', n, \sigma\rangle$. Comparing panel (a) and (b), if

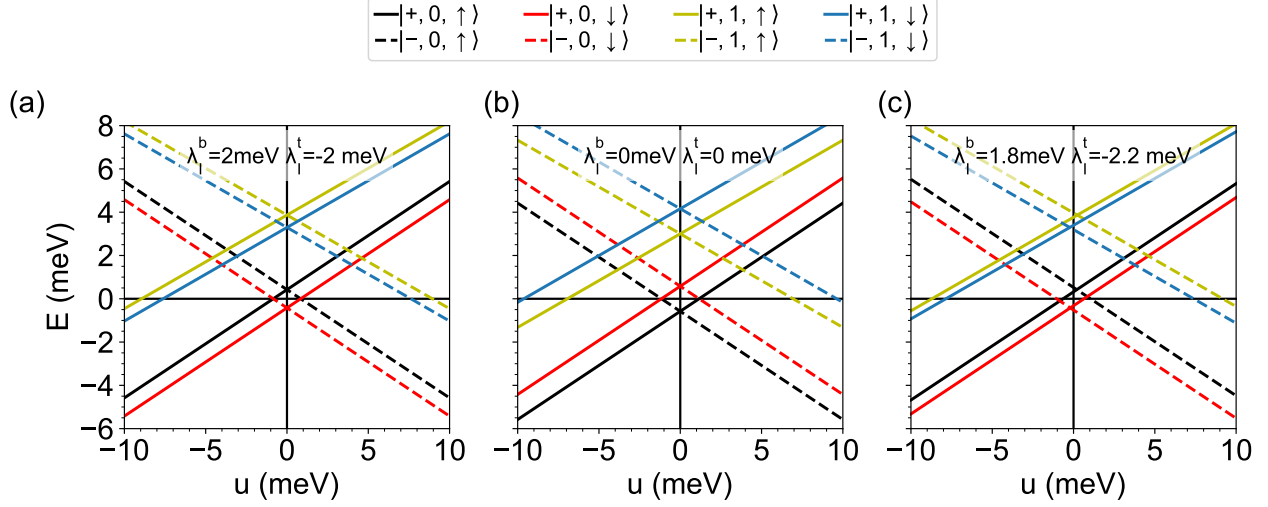


FIG. S5. Single-particle zeroth LL spectrum as a function of u at $B = 10$ T for (a) $\lambda_I^b = -\lambda_I^t = -2$ meV, (b) $\lambda_I^b = \lambda_I^t = -0$ and (c) $\lambda_I^b = 1.8$ meV and $\lambda_I^t = -2.2$ meV.

$\lambda_I^t = -\lambda_I^b$, at high magnetic field, the spectrum seems very similar to the case without SOC, however, the order of the spin up and spin down levels flip. Moreover, the positions (u^*) where two LLs cross also change, which we defined as D^* crossings in the measurements in the main text. In the third case, shown in panel (c), when λ_I^t and λ_I^b have an opposite sign but their magnitudes are different, the $u, -u$ symmetry is lost leading to a non-zero $\pm u_3^*$ crossings.

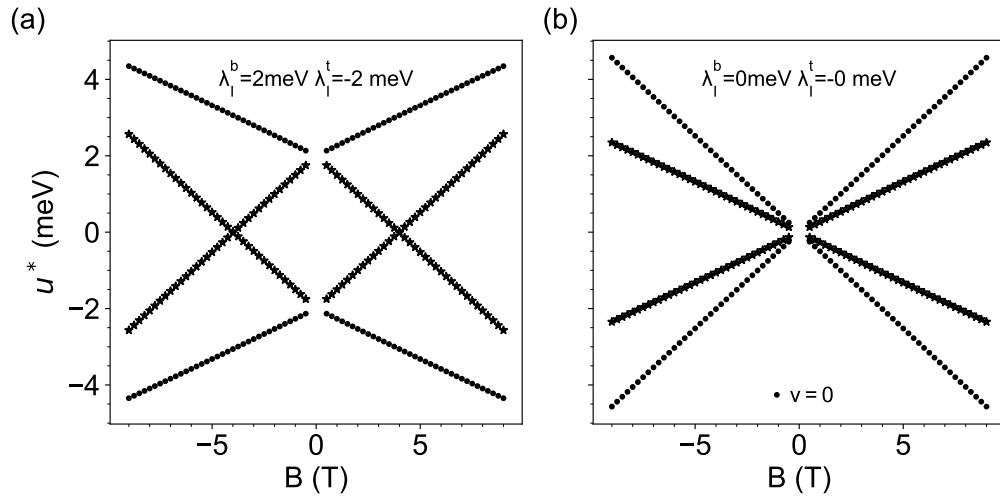


FIG. S6. Landau level crossings at $\nu = 0$ as a function of B with (a) $\lambda_I^b = -\lambda_I^t = -2$ meV and with (b) $\lambda_I^b = \lambda_I^t = -0$.

In Fig. S6. and Fig. S7. we plot the Landau level crossings, with SOC and without SOC, for $\nu = 0$ and $\nu = \pm 1$, respectively. Without SOC the crossings go to zero as $B \rightarrow 0$ as opposed to the case of $\lambda_I^b = -\lambda_I^t \neq 0$. Comparing these figures with Fig 4. in the main text, the experiments show similarities to the model: the $\nu = 1$ crossings show similar tendency, so do the higher u_0^* branches in the $\nu = 0$ crossings. Likely the discrepancy between the model calculated in a single-particle picture and the experiment comes from the fact that in our calculations we neglect electron-electron interactions [S6].

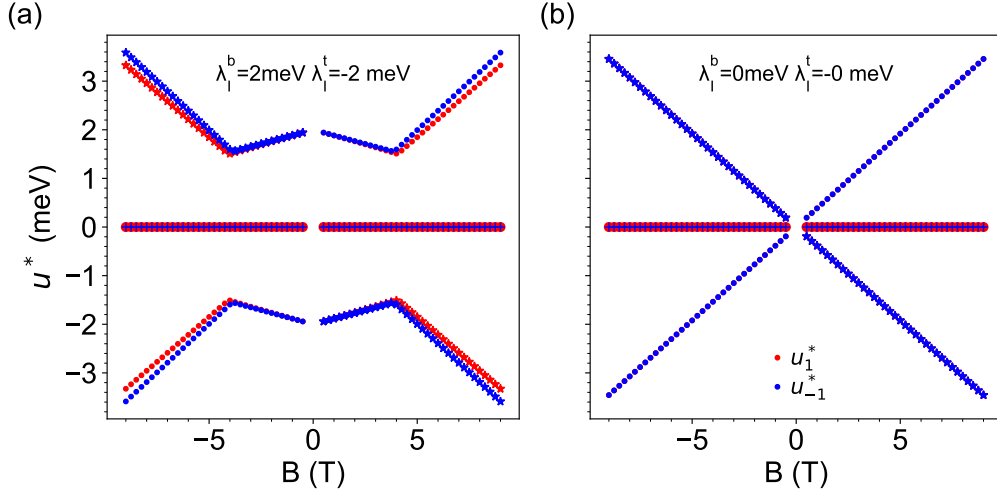


FIG. S7. Landau level crossings at $\nu = \pm 1$ as a function of B with (a) $\lambda_I^b = -\lambda_I^t = -2 \text{ meV}$ and with (b) $\lambda_I^b = \lambda_I^t = 0$.

S3. DETERMINATION OF THE LEVER ARMS

As discussed in the main text, to tune the charge carrier density n and the transverse displacement field D in the sample, gate voltages are applied to the metallic topgate (V_{TG}) and the graphite bottom gate (V_{BG}). The conversion from gate voltages to n and D is shown in Fig. S8 and is given by the following relation:

$$\begin{aligned}
 n &= \alpha_{TG} V_{TG} + \alpha_{BG} V_{BG} + n_0 \\
 \frac{D}{\epsilon_0} &= \frac{e}{2\epsilon_0} (\alpha_{TG} V_{TG} - \alpha_{BG} V_{BG}) + \frac{D_0}{\epsilon_0},
 \end{aligned}
 \tag{S9}$$

where ϵ_0 is the vacuum permittivity, e is the elementary charge, $\alpha_{BG, TG}$ are the lever arms of the bottom and topgate, respectively, while n_0 and D_0 are the offset charge carrier density

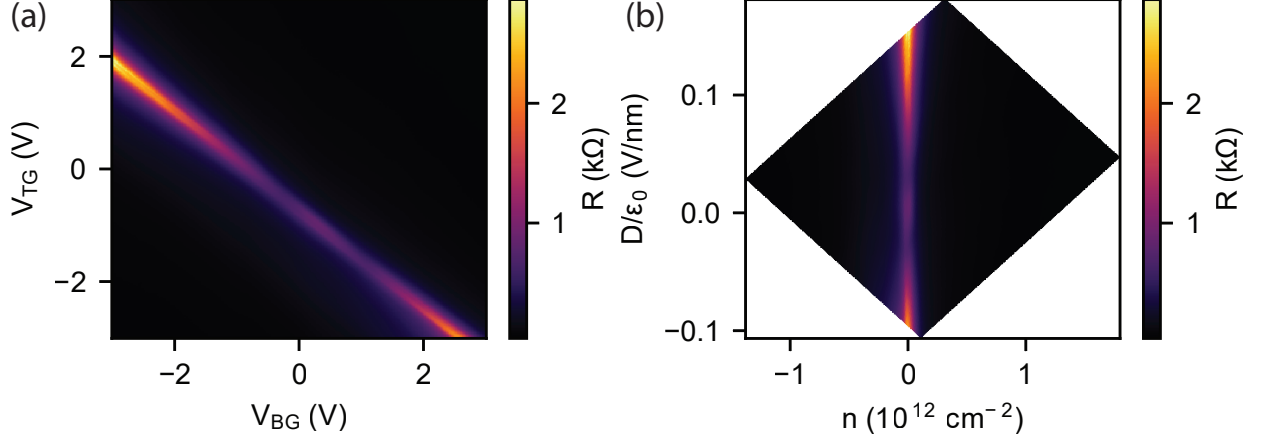


FIG. S8. Conversion from a) gate voltages to b) charge carrier density n and transverse displacement field D .

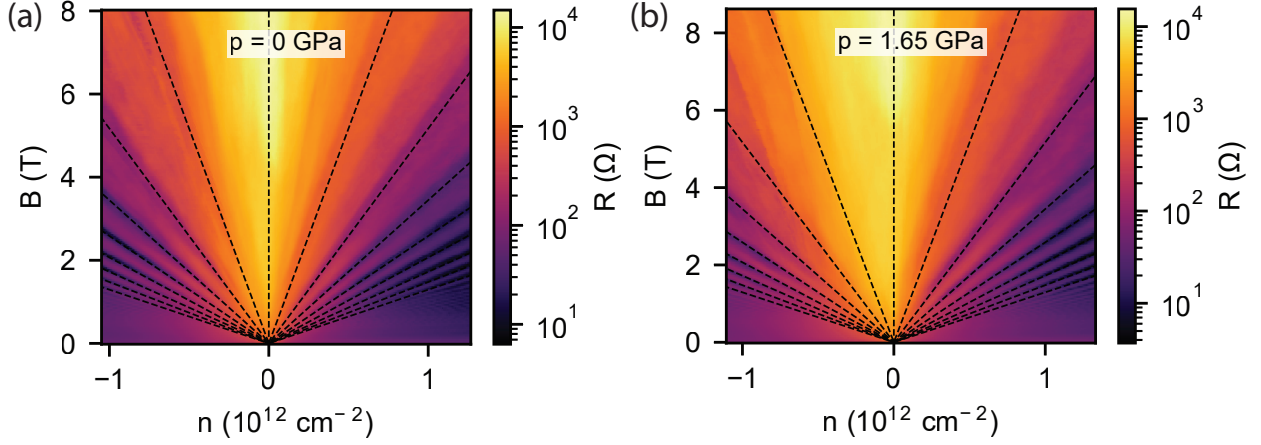


FIG. S9. Landau fan diagram of the resistance for a) $p = 0$ and b) $p = 1.65$ GPa at $D = 0$. Dashed lines correspond to carrier densities with filling factors $\nu = 4k$, where $k \in \mathbb{Z}$.

and displacement field. Since the lever arms are subject to change after the hydrostatic pressure is applied, originating from the compression of dielectrics, we determine them experimentally. First, the ratio of lever arms α_{BG}/α_{TG} can be obtained from gate voltage maps of the resistance (e.g. Fig. S8.a), as it is given by the slope of the charge neutrality line. Secondly, by measuring the fan diagram of Landau levels for $D = 0$, we determine the lever arms via the relation $\nu = nh/eB$ between the filling factor ν and the carrier density n for a given magnetic field B , where h is Planck's constant. The values of the lever arms can be found in Table S1.

p (GPa)	α_{BG} ($10^{15} \text{ V}^{-1}\text{m}^{-2}$)	α_{TG} ($10^{15} \text{ V}^{-1}\text{m}^{-2}$)
0	2.47 ± 0.08	2.81 ± 0.10
1.65	2.82 ± 0.07	3.12 ± 0.09

TABLE S1. Lever arms determined from quantum Hall measurements.

S4. DETERMINATION OF THE SOI PARAMETERS

To obtain the SOI strength from thermal activation measurements, electric displacement field D has to be converted to the induced interlayer potential difference u . As described in the main text, this is done via the relation $u = -\frac{ed}{\epsilon_0\epsilon_{\text{BLG}}}D$. For ambient pressure, $d = 3.3 \text{ \AA}$ can be taken, similarly to pristine BLG. On the other hand, we can only estimate ϵ_{BLG} from theoretical works. Since in the large u limit, the band gap induced by the displacement field is independent of the SOI parameters, by varying ϵ_{BLG} , we can effectively "fit" our model to the experimental data. Fig. S10.a shows the extended thermal activation data (partially presented in the main text) measured while warming up (red symbols) and cooling down (blue symbols) the sample for $p = 0$. As it is visible, in the band insulator regimes for $u \ll 0$ and $u \gg 0$, the data have different slopes. We correct for this effect by taking the

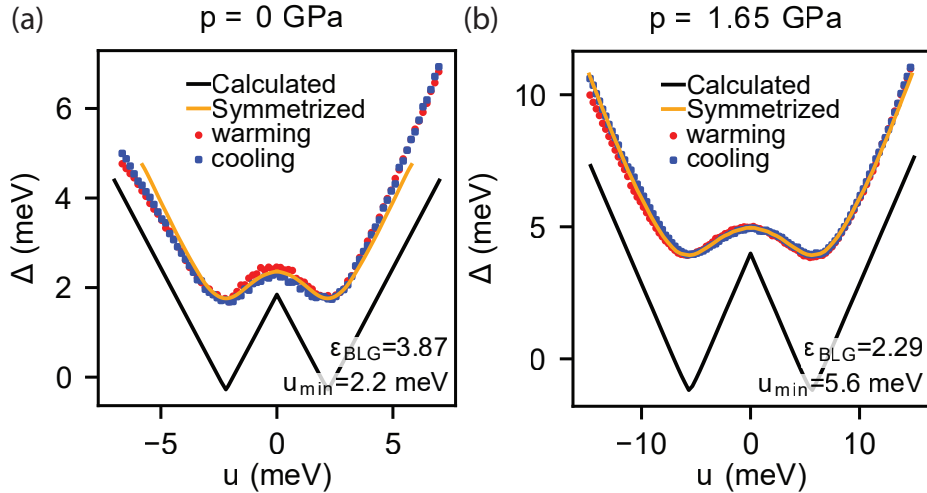


FIG. S10. Band gaps determined from thermal activation measurements performed while warming up (red) and cooling down (blue) the device for a) $p = 0$ and b) $p = 1.65$ GPa, respectively. Symmetrized curve with respect to $u = 0$ is shown in orange (see text for details) and the band gap calculated from the theoretical model is shown with the solid black line.

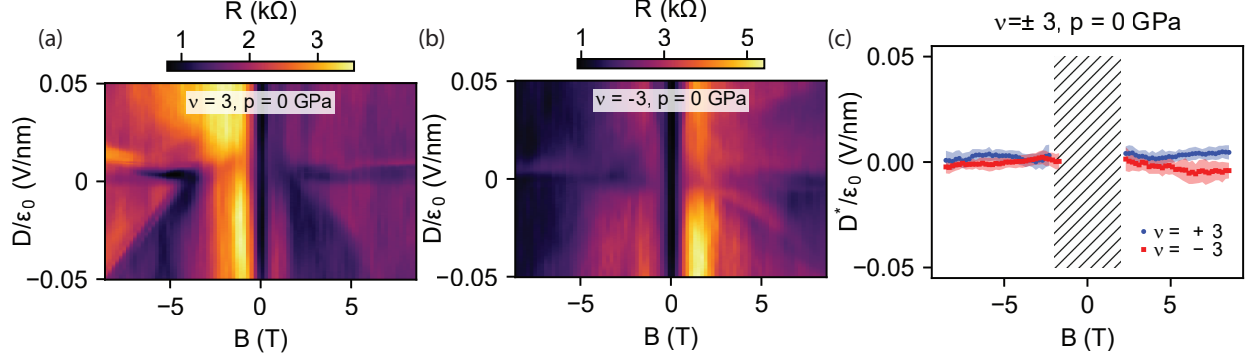


FIG. S11. a,b) Measurements of LL crossings as a function of B for $\nu = +3$ and $\nu = -3$, respectively, for $p = 0$. c) Positions of the LL crossings extracted from the maps in a) and b) for $\nu = +3$ (blue) and $\nu = -3$ (red).

average of the two measurements and symmetrizing it with respect to $u = 0$ (solid orange line). In the next step, we determine ϵ_{BLG} by matching the slope of the high- u part of the data to match the slope of the theoretical model (solid black line). Finally, we numerically determine the position u_{min} of the band gap minimum of the symmetrized curve and take the Ising SOI parameters as $\lambda_t = -\lambda_b = u_{\text{min}}$. We estimate the lower and upper bound of the SOI parameter by fitting the slope of the theoretical curve to the $u \ll 0$ and $u \gg 0$ parts of averaged band gaps, respectively, yielding $\lambda_t = -\lambda_b = 2.2 \pm 0.4$ meV for $p = 0$ and $\lambda_t = -\lambda_b = 5.6 \pm 0.6$ meV for $p = 1.65$ GPa.

We also have to note that, although we assumed that $|\lambda_I^b| = |\lambda_I^t|$, our method of determining the SOI parameters is only sensitive to the absolute difference of the two parameters since this quantity defines the closing of the band gap. In other words, the minima of the $\Delta(u)$ functions shown in Fig. S10 are insensitive to a difference in the absolute values of $|\lambda_I^{b,t}|$ as long as $|\lambda_I^t - \lambda_I^b|/2$ is constant. However, we can estimate the asymmetry of $|\lambda_I^{b,t}|$ by measuring the $\nu = \pm 3$ LL crossings since, within our model, the positions of these crossings in u are separated by $u_{+3}^* - u_{-3}^* \approx |\lambda_I^t| - |\lambda_I^b|$, nearly insensitive to the magnetic field. Measurements of the LL crossings as a function of D and B for $\nu = +3$ and $\nu = -3$ are shown in Fig. S11.a,b, respectively. Fig. S11.c shows the extracted positions D^* of the crossings for $\nu = \pm 3$. As it is visible, for the most part of our magnetic field range, the positions of the crossings are indistinguishable. At higher magnetic field we see crossings at $u_{\pm 3}^* \neq 0$, indicating a small asymmetry of the SOC parameters. From these, we can estimate the upper bound of the asymmetry as $|\lambda_I^t| - |\lambda_I^b| < 0.4$ meV for $p = 0$.

S5. EXTENDED QUANTUM HALL MEASUREMENT DATA

Additional data for the quantum Hall measurements at $p = 1.65$ GPa is shown in fig. S12.

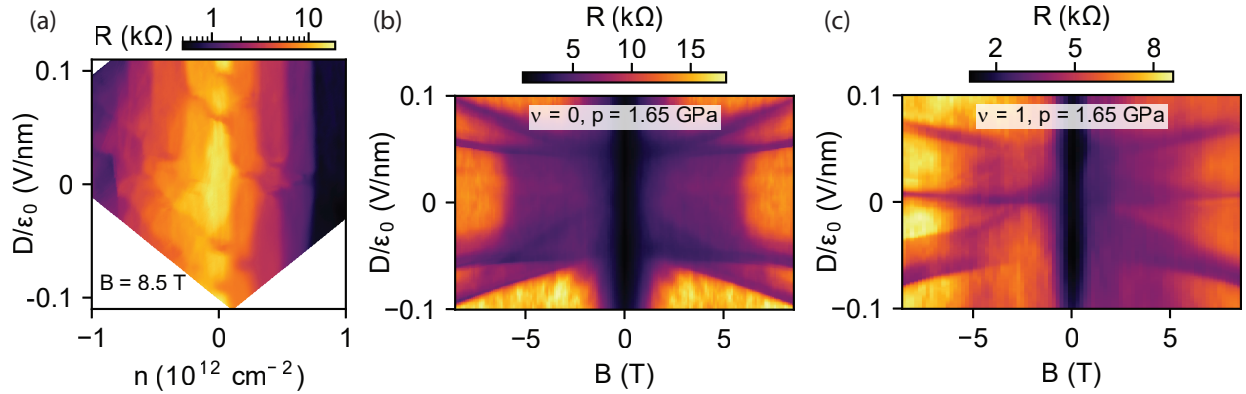


FIG. S12. Extended data for Fig. 4. of the main text. a) n - D map of the resistance measured at $B = 8.5$ T and $p = 1.65$ GPa. b,c) Measurements of LL crossings as a function of B for $\nu = 0$ and $\nu = 1$, respectively, at $p = 1.65$ GPa.

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